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## APPLICANTS

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\*\* CONTINUING DATA *yes* \*\*\*\*\*

This application is a DIV of 09/880,932 06/15/2001 ABN

\*\* FOREIGN APPLICATIONS *Parent* \*\*\*\*\*

JAPAN 2000-193734 06/28/2000

JAPAN 2001-067042 03/09/2001

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35 USC 119 (a-d) conditions met <input checked="" type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> Met after Allowance				
Verified and Acknowledged <i>[Signature]</i> Examiner's Signature	<i>[Initials]</i> Initials			

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## TITLE

Hexagonal boron nitride film with low dielectric constant, layer dielectric film and method of production thereof, and plasma CVD apparatus

☐ All Fees